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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/634,997 Confirmation No. : 7492
First Named Inventor : Shinichi SUMIDA
Filed : August 6, 2003
TC/A.U. : 1713
Examiner : H. S. Hu
Docket No. : 038788.52654US
Customer No. : 23911
Title : Fluorine-Containing Compounds and Their Polymers
Useful for Anti-Reflection Film Materials and Resist
Compositions

REPLY TO OFFICE ACTION

Mail Stop Amendment

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is a Reply to the Office Action mailed May 11, 2005 in the above-identified patent application.

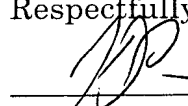
Responsive to the requirement for restriction, applicants hereby elect the claims of Group II, namely claims 2, 5, 7, 9 and 12, for examination in the instant application. Prompt, favorable action on the application is earnestly solicited.

If there are any questions regarding this response or the application in general, a telephone call to the undersigned at (202) 624-2845 would be appreciated since this should expedite the prosecution of the application.

If necessary to effect a timely response, this paper should be considered as a petition for an Extension of Time sufficient to effect a timely response, and please charge any deficiency in fees or credit any overpayments to Deposit Account No. 05-1323 (Docket # 038788.52654US).

June 10, 2005

Respectfully submitted,



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